

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	11	427/255.25.ccor.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/07 09:10
L2	0	427/22.ccor.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/07 09:10
L3	178	427/252.ccor.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/07 09:10
L4	58	L3 and @ad<"20000329"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/07 09:14
L5	1002	438/3.ccor.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/07 09:19
L6	269	L5 and @ad<"20000329"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/07 09:20
L7	548	438/680,681,683,685.ccor.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/07 09:29
L8	211	L7 and @ad<"20000329"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/07 09:20

L9	0	(438/680,681,683,685 427/252,255. 25).ccor. and (LSMCD (misted adj cvd) and active and (kinetic adj energy)).clm.	US-PGPUB	OR	ON	2005/10/07 09:31
S2	9	S1 and @ad<"20000329"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/07 09:10
S42	34	ceramic and (LSMCD (misted adj Cvd))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/06 16:13
S43	1	S42 and @ad<"20000329"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/06 16:14
S44	122	LSMCD (Liquid adj Source adj Misted adj Chemical adj Deposition)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/06 16:45
S45	22	S44 and @ad<"20000329"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/06 17:18
S46	11	(misted adj chemical adj vapor adj deposit\$3) (misted adj cvd)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/06 17:18
S47	5	S46 and @ad<"20000329"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/10/07 09:04